



Comparison of commercial Hamamatsu SiPM with the new custom samples

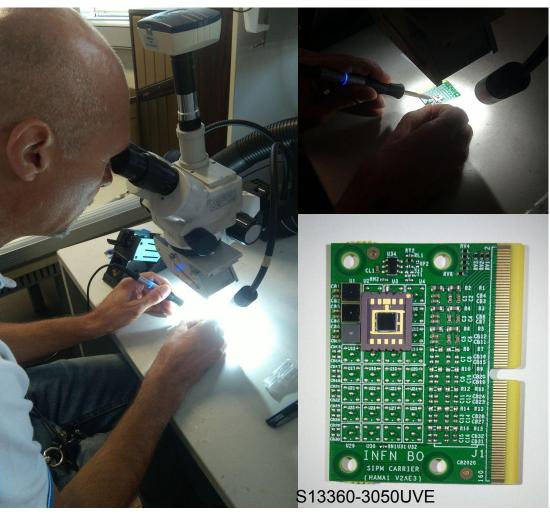
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ePIC-dRICH meeting 04/06/2025

Hamamatsu UVE SiPM prototypes

2024 test samples



newly-developed Hamamatsu SiPM sensors

based on S13360 series

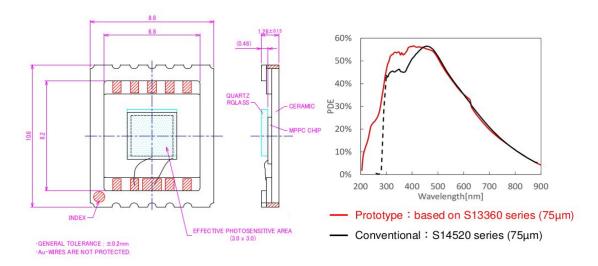
few samples of 50 µm and 75 µm SPAD sensors

on paper they look VERY promising

- improved NUV sensitivity
- improved signal shape
- improved recharge time

mounted on EIC SiPM test boards characterised and tested them

irradiation, annealing, laser, ...

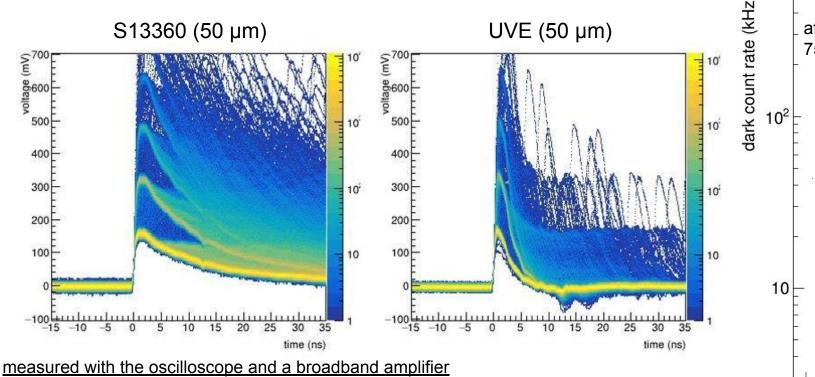


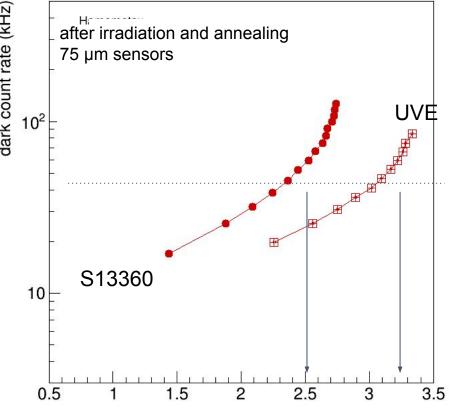
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Hamamatsu UVE SiPM prototypes

we compared the standard commercial Hamamatsu S13360 sensors with the UVE sample devices





UVE sensors have > 5x faster recharge time with the same signal amplitude

→ lower pile-up probability at high DCR

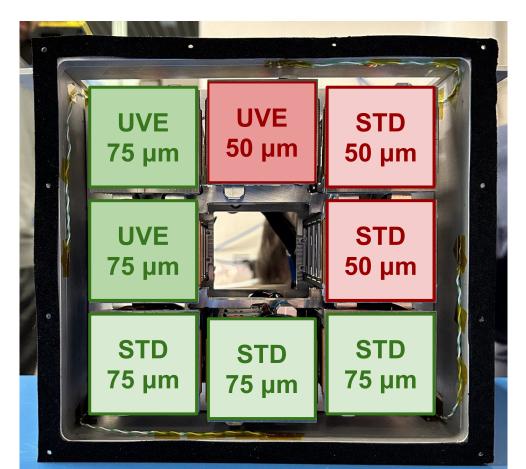
signal coincidences / triggers (%) measured with the ALCOR electronics readout chain

UVE sensors have > 30% higher PDE at the same DCR of 50 kHz

note: this is measured with a 400 nm laser and the prototype have a quartz protective window check with Hamamatsu for custom devices with silicone protective window

Hamamatsu UV-Enhanced SiPM optimisation

aim at a the next dRICH beam test to evaluate them with Cherenkov light



possible layout on the present prototype readout box

meeting with Hamamatsu engineers

- productive meeting in September 2024
- can provide what we want, namely
 - SiPM matrices 8x8 with UVE sensors
 - SMD mounting
 - silicone resin window

purchased and received

- 4x matrices with 50 μm SPADs
- 12x matrices with 75 μm SPADs
- several single-SiPM sensors

this

presentation

2025 test samples

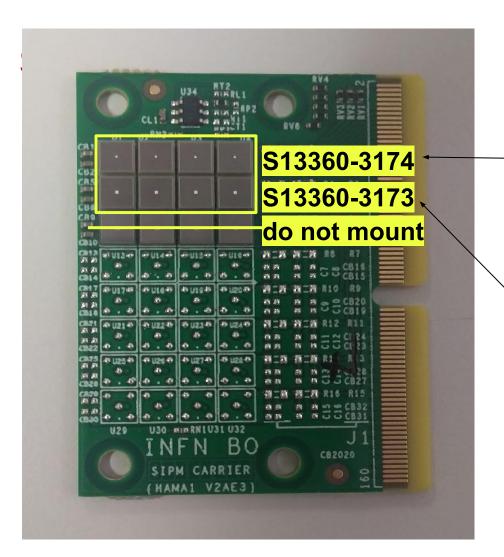
goal

assemble few new PDUs

- use them in the next beam test
- evaluate expected PDE improvement

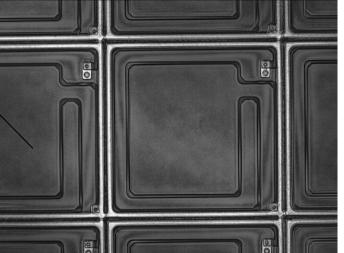


SiPM test boards with new UVE Hamamatsu



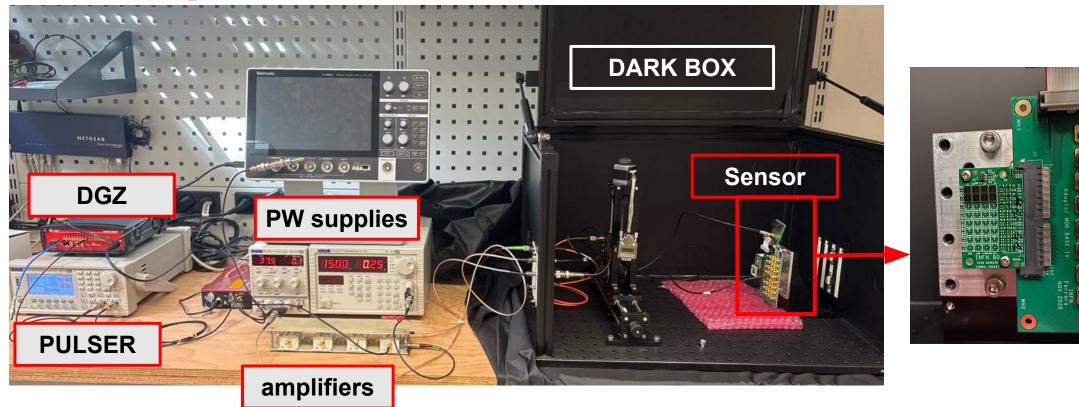


50 μm



75 μm

Setup



- CAEN Digitizer DT5742B
- Pulser (provides NIM trg to the DGZ + trg to the laser)
- 2 pw supplies (providing bias and powering the amplifier)
- Amplifier (Mini-circuits ZFL1000LN+)
- Linux desktop PC → controls digitizer, pw supplies, pulser

DARK BOX:

SiPM + carrier + adapter board

Setup - digitizer CAEN DT5742B

- CAEN DT5742B: 12-bit, 5 GS/s digitizer based on a DRS4 (Domino Ring Sampler) chip
- Designed for fast waveform acquisition, equipped with 16+1 channels for digitization (1 can be used as fast trigger) + external trigger (NIM)
- Full Scale Range: 1 Vpp
- It comes from CAEN with dedicated C Libraries



ANALOG INPUTS	Number of Channels 16 1 special channel (TR0) Single ended Full Scale Range (FSR) 1 V _{pp} (default) 2 V _{pp} (by customization) Absolute max analog input voltage (for any DAC offset) @1V _{pp} = 3 V _{pp} (with V _{rail} max +3V or -3V) @2V _{pp} = 6 V _{pp} (with V _{rail} max +6V or -6V)	Impedance $Z_{in} = 50 \Omega$ DC Offset Programmable 16-bit DAC for DC Offset adjustment on each channel. Range: $\pm 1 \text{ V}$
DIGITAL CONVERSION	Resolution 12 bits Switched Capacitor Array Domino Ring Sampler chip (DRS4), 8+1 channels with 1024 storage cells each	Sampling Rate 5 GS/s - 2.5 GS/s - 1 GS/s - 0.75 GS/s SW selectable, simultaneously on each channel

Signal amplification

- Amplifier: Mini-circuits ZFL-1000LN+
- Low-noise, operational range 0.1 1000 MHz
- Powered at 15 V
- 4-amplifier array available for future measurements with multiple channels at once

Maximum Ratings

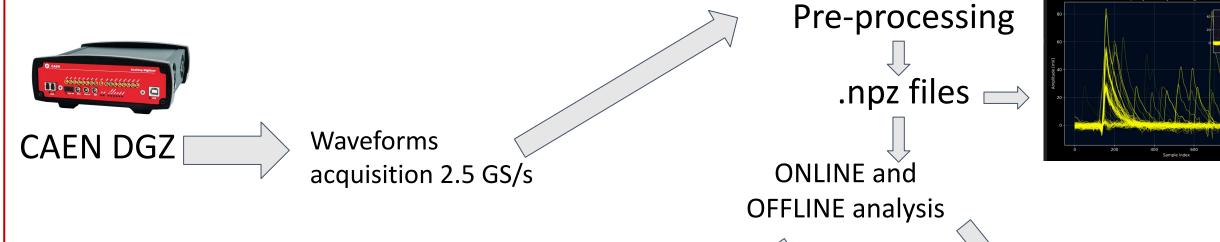
Parameter	Ratings
Operating Temperature	-20°C to 71°C
Storage Temperature	-55°C to 100°C
DC Voltage	17V
Input RF Power (no damage)	+5 dBm

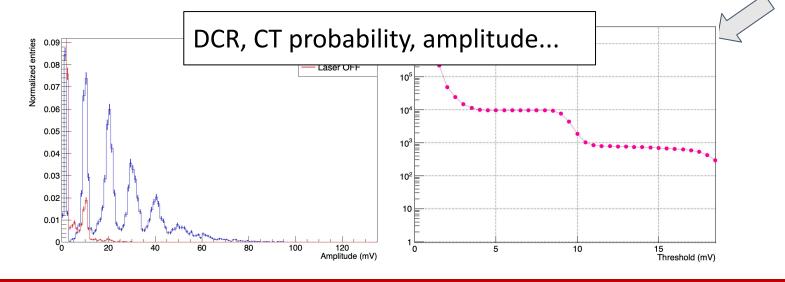
Permanent damage may occur if any of these limits are exceeded.

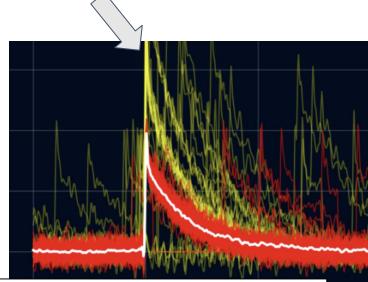




Data acquisition and analysis

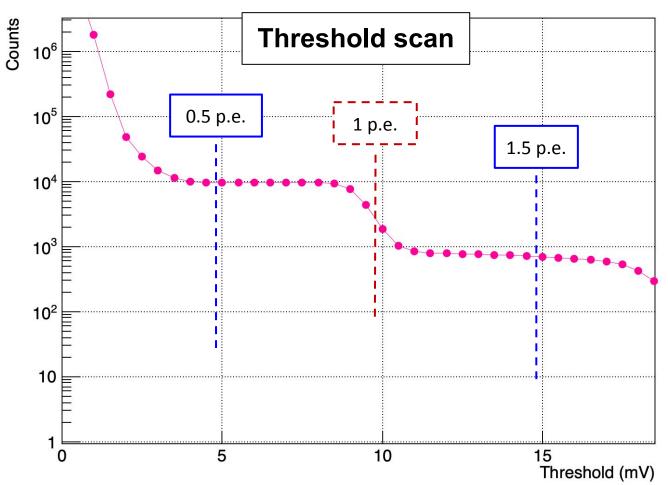






Signal visualization & analysis

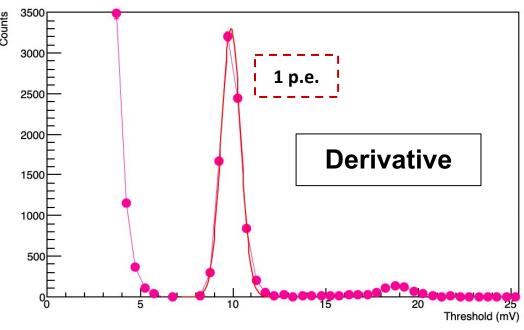
Dark analysis recipe



Example: sn31-A1 @54.5 V

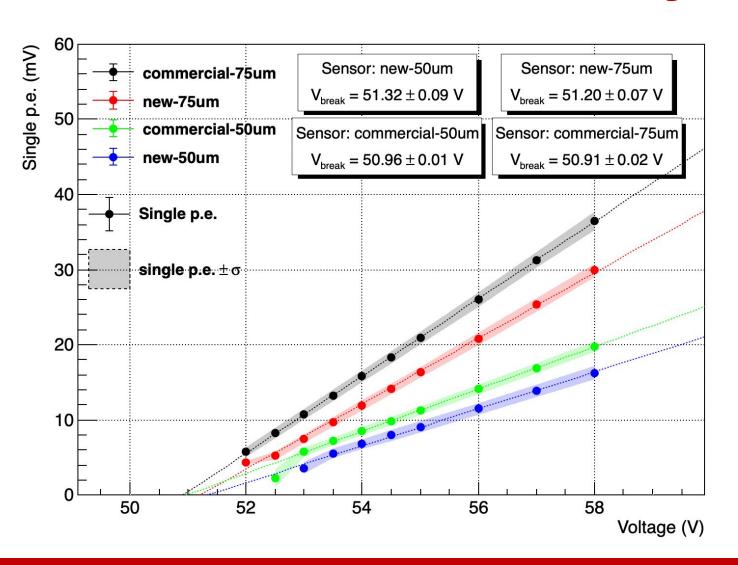
Our recipe:

- Threshold scan
- Derivative: gaussian fit on 1 p.e.
- DCR is defined at 0.5 p.e.
- CT is defined as ratio of the amplitude at 1.5 and 0.5 p.e.





Results of dark analysis

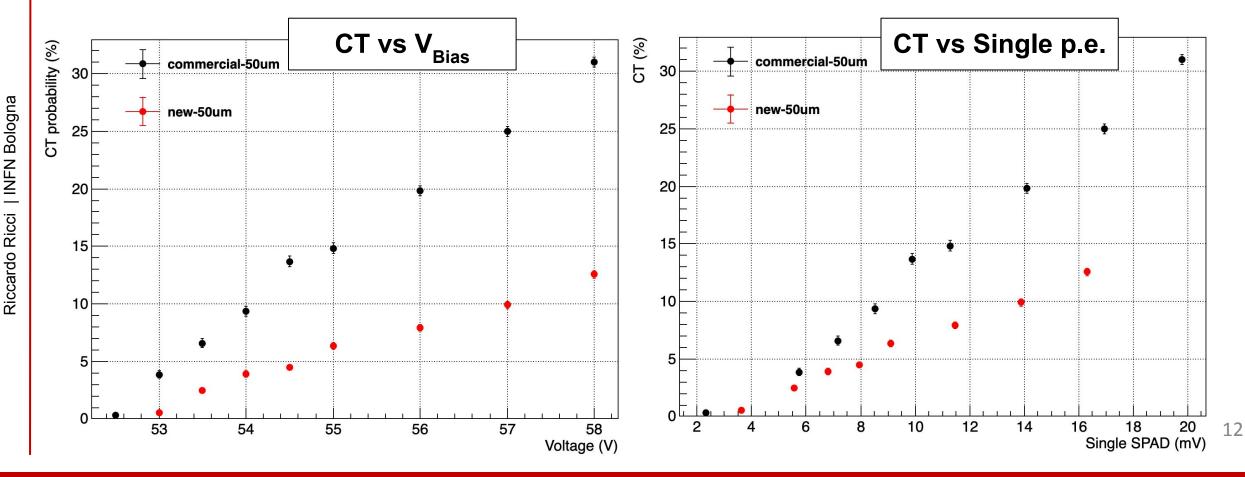


Single p.e. amplitude (mV) vs V_{bias}:

- Hint of a V_{Break} greater for custom sensors compared for commercial one
- The amplitude of commercial Hamamatsu sensors is greater compared to the customs

Results of dark analysis [50µm]

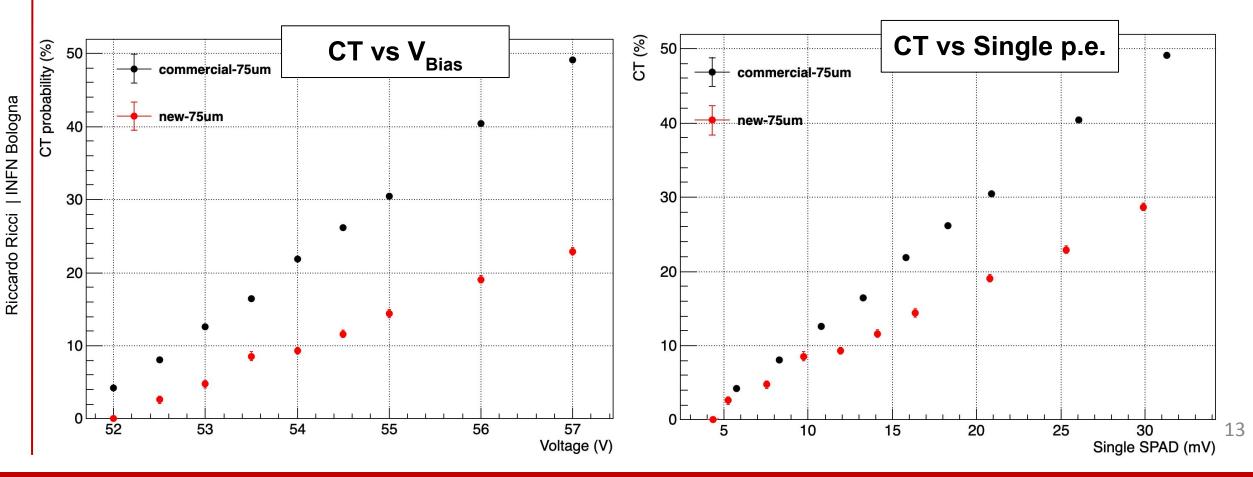
- General improvements in CT results
- Need to have a precise temperature stabilization





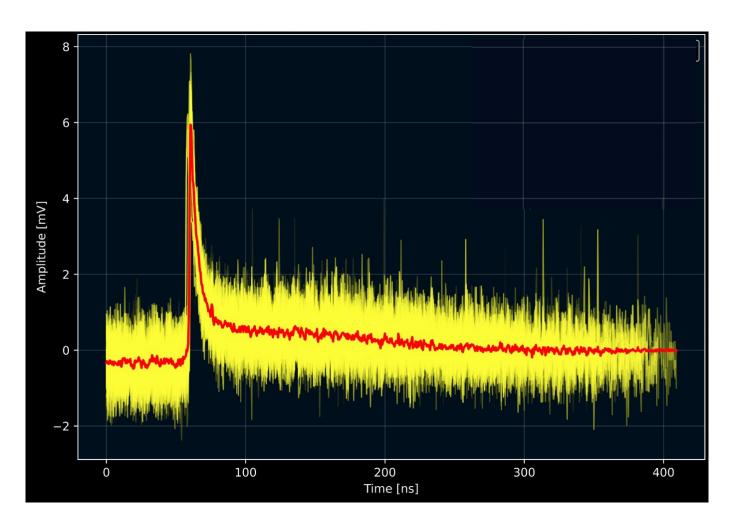
Results of dark analysis [75µm]

- General improvements in CT results
- Need to have a precise temperature stabilization





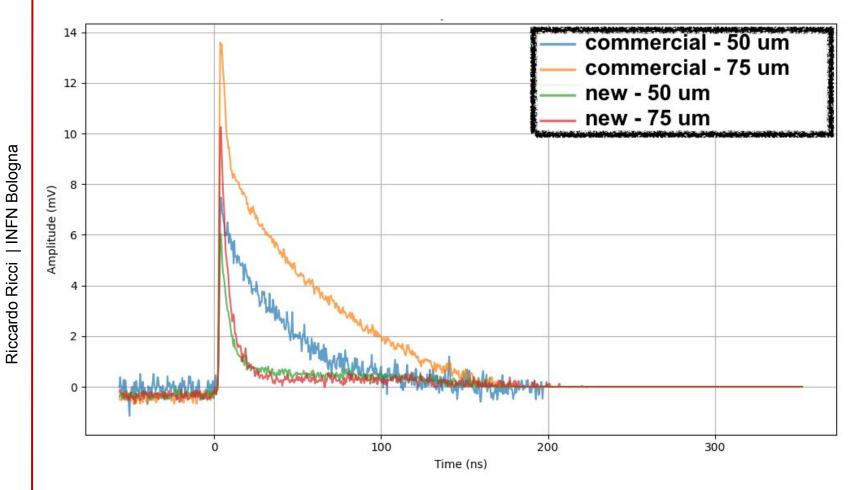
Persistence



- Only good waveforms selected (using threshold in amplitude)
- Peaks are identified and collected, then aligned at the rising edge
- to be perfectioned the individuation of the single-pe peak and exclusion of after-pulses
- the median waveform is used as input for a direct tau estimation



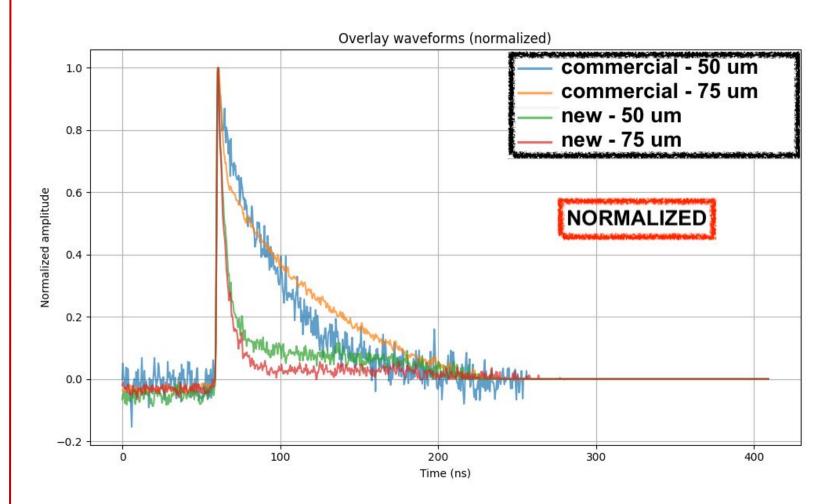
Persistence - sensor comparison



- measured at constant bias voltage:54 V
- waveform selection: waveform over threshold, single pe, no double peaks
- after selection → median
 - Breakdown voltage differs slightly between sensors → new sensors
 (board 41) may show lower signals than those on board 31 due to different overvoltage levels i.e. not the same operating point
- Same considerations applies to the next plots

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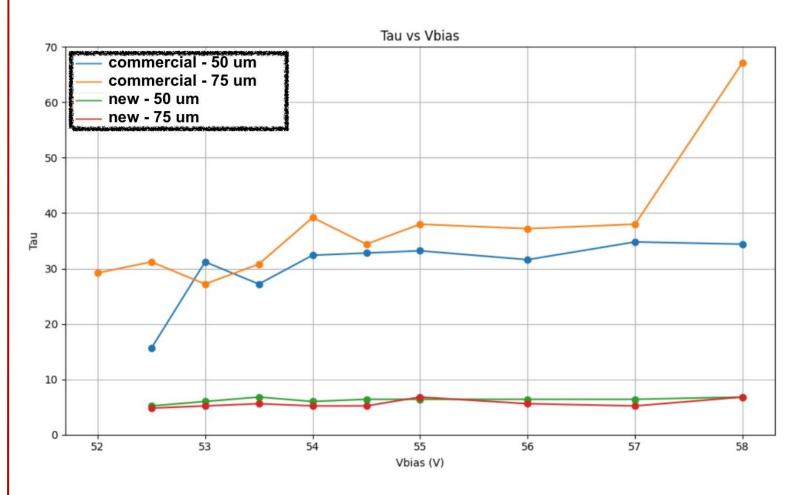
Persistence - sensor comparison



- measured at constant bias voltage:54 V
- waveform selection: waveform over threshold, single pe, no double peaks
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- Breakdown voltage differs slightly between sensors → new sensors (board 41) may show lower signals than those on board 31 due to different overvoltage levels i.e. not the same operating point
- Same considerations applies to the next plots

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Measurement of the tau



- waveform selection: waveform over threshold, single pe, no double peaks
- after selection:
 - → median (waveforms)
 - → decay constant(direct estimation)

$$\tau$$
= $t_{1/e}$ - t_{peak}



Summary and conclusions

- Preliminary comparison among commercial and new-custom Hamamatsu using a setup with CAEN digitizer DT5742B
- The system now is equipped with a server to take/download data + first version of a online analysis framework (work in progress)
- First results from the new sensors (custom) looks promising compared to the commercial ones

- These are the first measurements taken with a completely new setup
- The setup currently lacks any temperature stabilization
- In the upcoming weeks, we will work to improve and stabilize the system and the analysis





Backup

PPO DRS4 chip

- The DRS4 (Domino Ring Sampling 4) is the 4th generation of an ASIC chip designed for high-speed digitization of signals.
- Based on a switched-capacitor array, where analog voltages are temporarily stored in capacitors before being digitized.
- Each channel has 1024 storage cells acting as a circular buffer. A fast sequence of write pulses allows the recording of analog waveforms in the capacitors at high frequency, which can later be read out and digitised via ADCs at a much lower speed
- Sampling speed up to 5 GS/s (minimum 750 MS/s)
- Requires calibration to correct non-uniformities and offsets introduced by variations in capacitor properties and charge injection effects.

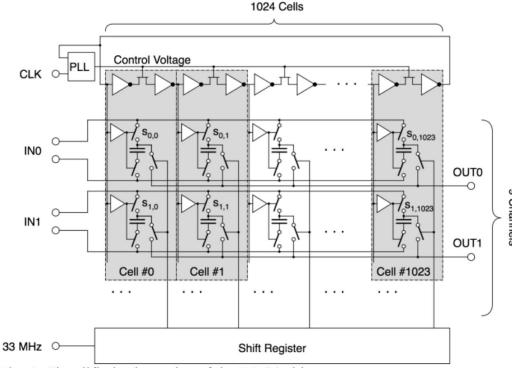
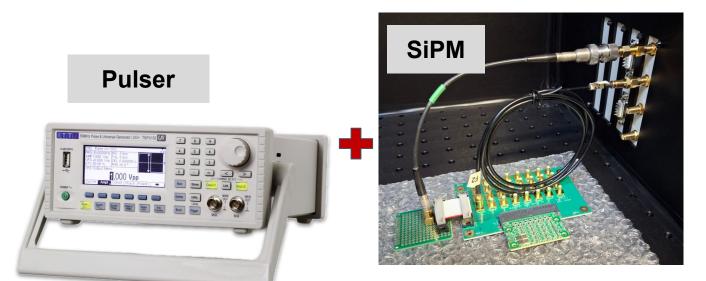


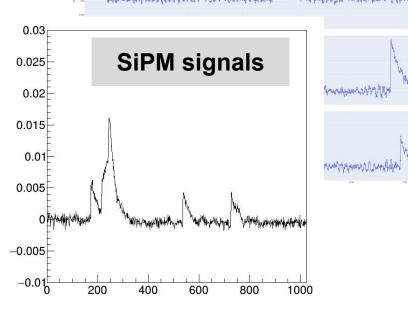
Fig. 1: Simplified schematics of the DRS4 chip.

First signal from a SiPM

SiPM setup:

- CAEN Digitizer DT5742 (connected to Linux PC via USB)
- AimTTi 2-channel pulse generator to provide trigger signal*
- SiPM and related setup (AimTTi PW supplies to provide bias to the sensor an power to the amplifier)
- Data visualization: python code working with CAEN Libraries or a modified (rewritten version) of wavedump

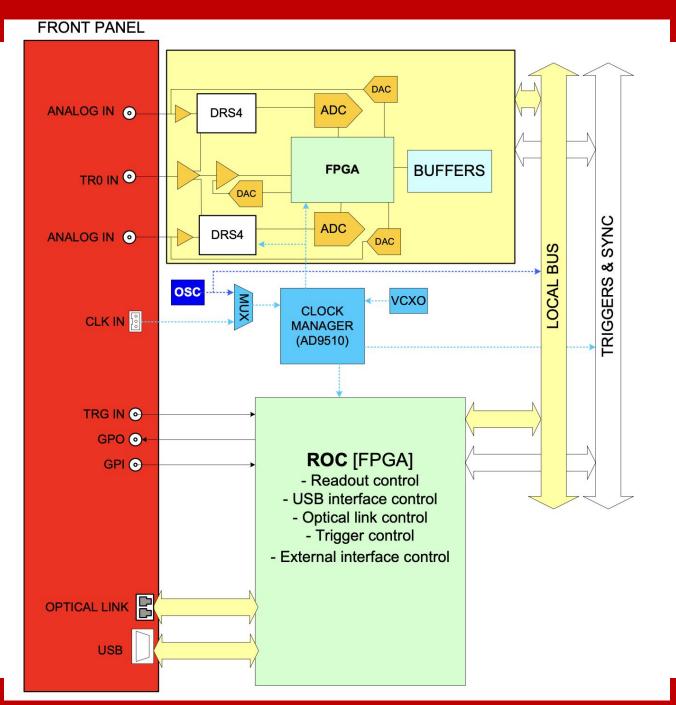






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PPI DGZ Scheme



Aimtti pulser specs

24.8 Outputs

24.8.1 Main Output

Amplitude: $100 \text{mVpp to } 10 \text{Vpp } 50\Omega \text{ into } 50\Omega$

200mVpp to 20Vpp 5Ω into 50Ω or 50Ω into open circuit

Amplitude Accuracy: $1.5\% \pm 5$ mV at 1kHz 50Ω into 50Ω

DC Offset Range: $\pm 5V$. DC offset plus signal peak limited to $\pm 5V$ from 50Ω into 50Ω

 ± 10 V. DC offset plus signal peak limited to ± 5 V from 5Ω into 50Ω or

 50Ω into open circuit

DC Offset Accuracy: Typically 1% ±50mV.

Resolution: 3 digits or 1mV for both Amplitude and DC Offset.

Source Impedance 5Ω or 50Ω selectable